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Search Results - Record(s) 1 through 4 of 4 returned.

1. Document ID: US 5498335 A

L36: Entry 1 of 4

File: USPT

Mar 12, 1996

US-PAT-NO: 5498335

DOCUMENT-IDENTIFIER: US 5498335 A

TITLE: Process for forming porous polmyeric product from a nonporous polymeric

composition and product

DATE-ISSUED: March 12, 1996

INVENTOR-INFORMATION:

NAME

CITY

STATE

NH

ZIP CODE

COUNTRY

Moya; Wilson

Derry

US-CL-CURRENT: 210/490; 210/500.38, 210/500.41, 210/500.42

Full | Title | Citation | Front | Review | Classification | Date | Reference | Sequences | Attachments |

K006C

.....

2. Document ID: US 5277811 A

L36: Entry 2 of 4

File: USPT

Jan 11, 1994

US-PAT-NO: 5277811

DOCUMENT-IDENTIFIER: US 5277811 A

TITLE: Process for forming porous polymeric product from a nonporous polymeric

composition and product

DATE-ISSUED: January 11, 1994

INVENTOR-INFORMATION:

NAME

CITY

STATE

ZIP CODE

COUNTRY

Moya; Wilson

Derry

NH

US-CL-CURRENT: 210/500.3; 210/500.36, 210/500.38, 210/500.4, 210/500.41

Full: Title Citation Front Review Classification Date Reference Sequences Attachments

1006C

3. Document ID: US 5271839 A

L36: Entry 3 of 4

File: USPT

Dec 21, 1993

US-PAT-NO: 5271839

DOCUMENT-IDENTIFIER: US 5271839 A

TITLE: Patterned porous polymeric product and process

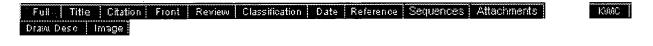
DATE-ISSUED: December 21, 1993

INVENTOR-INFORMATION:

NAME CITY STATE ZIP CODE COUNTRY

Moya; Wilson Derry NH Cook; Paul J. Manchester MA

US-CL-CURRENT: 210/490; 210/500.29, 210/500.38, 210/500.41, 210/500.42



4. Document ID: US 4761233 A

L36: Entry 4 of 4 File: USPT Aug 2, 1988

US-PAT-NO: 4761233

DOCUMENT-IDENTIFIER: US 4761233 A

TITLE: Novel membranes and process for making them

DATE-ISSUED: August 2, 1988

INVENTOR-INFORMATION:

NAME CITY STATE ZIP CODE COUNTRY

Linder; Charles Rehovot IL
Perry; Mordechay Petach Tikvah IL
Ketraro; Reuven Rishon LeZion IL

US-CL-CURRENT: 210/500.37; 210/500.38, 210/500.4, 210/500.41, 264/216, 264/331.19, 264/41

Full Titl	e Citation	Front Review	Classification	Date	Reference	Sequences	Attachments	TOMC
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Search History

DATE: Friday, December 05, 2003 Printable Copy Create Case

Set Name side by side	* *	Hit Count	Set Name result set
$DB = U_{i}$	SPT; PLUR=YES; OP=ADJ		
<u>L37</u>	L36 and charged particles	0	<u>L37</u>
<u>L36</u>	L33 and etching	4	<u>L36</u>
<u>L35</u>	L33and etching	0	<u>L35</u>
<u>L34</u>	L33and etched	0	<u>L34</u>
<u>L33</u>	L32 and polyimide	73	<u>L33</u>
<u>L32</u>	((210/500.38)!.CCLS.)	394	<u>L32</u>
<u>L31</u>	((156/273.2)!.CCLS.)	0	<u>L31</u>
<u>L30</u>	((156/273.2)!.CCLS.)	0	<u>L30</u>
<u>L29</u>	((156/273.2)!.CCLS.)	0	<u>L29</u>
<u>L28</u>	L25 and etched	1	<u>L28</u>
<u>L27</u>	L25 and charged particles	0	<u>L27</u>

<u>L26</u>	L25 and irradiation	0	<u>L26</u>
<u>L25</u>	123 and membrane	5	<u>L25</u>
<u>L24</u>	L23 and charged particles	0	<u>L24</u>
<u>L23</u>	((156/305)!.CCLS.) and polyimide	35	L23
<u>L22</u>	L21 and polyimide	1	<u>L22</u>
<u>L21</u>	L20 and membrane	2	<u>L21</u>
<u>L20</u>	L19 and etching	22	<u>L20</u>
<u>L19</u>	((156/305)!.CCLS.)	885	<u>L19</u>
<u>L18</u>	etching and ((156.252/)!.CCLS.)	0	<u>L18</u>
<u>L17</u>	etchin and ((156.252/)!.CCLS.)	0	<u>L17</u>
<u>L16</u>	L15 and etching	32	<u>L16</u>
<u>L15</u>	charged particles and kapton	125	<u>L15</u>
<u>L14</u>	L13 and membrane	20	<u>L14</u>
<u>L13</u>	irradiated and kapton and etched	86	<u>L13</u>
<u>L12</u>	track etched same kapton	0	<u>L12</u>
<u>L11</u>	L10 and kapton	1	<u>L11</u>
<u>L10</u>	track etching same polyimide	5	<u>L10</u>
<u>L9</u>	polyimide same membrane and track same etched	11	<u>L9</u>
<u>L8</u>	Lr and polimide same membrane	0	<u>L8</u>
<u>L7</u>	L6 and polyimide	0	<u>L7</u>
<u>L6</u>	L5 and track etched	1	<u>L6</u>
<u>L5</u>	((210/500.39)!.CCLS.)	142	<u>L5</u>
<u>L4</u>	kapton same track etched	0	<u>L4</u>
<u>L3</u>	L2 and "track etched"	11	<u>L3</u>
<u>L2</u>	L1 and etched	105	<u>L2</u>
<u>L1</u>	kapton and membrane and polyimide	337	<u>L1</u>

END OF SEARCH HISTORY